Atomic Layer Deposition Encapsulated Activated Carbon Electrodes for High Voltage Stable Supercapacitors

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Supporting Information

ABSTRACT: Operating voltage enhancement is an effective route for high energy density supercapacitors. Unfortunately, widely used activated carbon electrode generally suffers from poor electrochemical stability over 2.5 V. Here we present atomic layer deposition (ALD) encapsulation of activated carbons for high voltage stable supercapacitors. Two-nanometer-thick Al₂O₃ dielectric layers are conformally coated at activated carbon surface by ALD, well-maintaining microporous morphology. Resultant electrodes exhibit excellent stability at 3 V operation with 39% energy density enhancement from 2.5 V operation. Because of the protection of surface functional groups and reduction of electrolyte degradation, 74% of initial voltage was maintained 50 h after full charge, and 88% of capacitance was retained after 5000 cycles at 70 °C accelerated test, which correspond to 31% and 17% improvements from bare activated carbon, respectively. This ALD-based surface modification offers a general method to enhance electrochemical stability of carbon materials for diverse energy and environmental applications.

KEYWORDS: atomic layer deposition, supercapacitor, electrode, activated carbon, encapsulation

INTRODUCTION

A supercapacitor is a typical high power energy storage device, widely exploited for portable electronics, electric vehicles and so on.1−3 Because electrical energy is restored by charge separation in a Helmholtz double layer,4−10 electrode material is the crucial element to govern the ultimate performance of supercapacitors. Presently, supercapacitor electrodes principally rely upon activated carbons with large surface area, good electrochemical stability, and low cost.4,9,10 Unfortunately, activated carbon electrodes commonly suffer from high leakage current, which results in self-discharge and low efficiency charging/discharging cycles with a significant amount of energy waste.11−13 Because leakage current increases exponentially with applied voltage,14,16 how to minimize leakage current is a critical issue for high performance supercapacitor particularly operating at high voltages.

Currently, fully charged voltage of single-cell commercial supercapacitor typically ranges from 2.5 to 2.7 V. Since specific energy of carbon/carbon capacitor scales with the square of fully charged voltage, enhancement of operating voltage is a facile route for large energy density.7,17 It is possible to increase the operating voltage over 2.7 V by differentiating the relative masses of the two electrodes.18−21 However, such an asymmetric design inevitably sacrifices charge capacitance. By contrast, in a symmetric design, the capacitance fading for cycle occurs rapidly under a high operating voltage over 2.5 V. This is principally due to the decomposition of the electrolyte at electrode surface, which can be further accelerated in the presence of surface functional groups.5,22−26

In this work, we introduce high-voltage-stable, high-performance activated carbon electrodes encapsulated with ultrathin Al₂O₃ dielectric layer by atomic layer deposition (ALD). ALD is a unique process that enables conformal coating of ultrathin layers at three-dimensional structures with atomic scale thickness controllability.27−34 Our ALD-assisted process is free from the time-consuming thermal annealing process and thereby remarkably reduces processing time for carbon activation process. Activated carbon encapsulated with ultrathin Al₂O₃ layer demonstrates excellent electrochemical stability and exhibits remarkably performance enhancements in energy density (46 Wh kg⁻¹) as well as power (86 kW kg⁻¹) at 3 V operation (33 Wh kg⁻¹, 60 kW kg⁻¹ at 2.5 V operation). These results are among the most advanced values reported thus far for the supercapacitor based on typical activated carbon electrodes.35−47

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RESULTS AND DISCUSSIONS

Our procedure for supercapacitor fabrication is briefly described in Figure 1a. In contrast to the conventional carbon activation process (see Figure S1a in the Supporting Information), thermal annealing and vacuum drying steps are replaced with ALD process. This simplification is advantageous for low production cost with minimum time delay (from 24 h to 10 min). Figure 1b schematically illustrates ALD process of ultrathin Al2O3 layer. Trimethylaluminum (TMA) and H2O precursors are alternately supplied for controlled Al2O3 deposition. First, TMA is exposed on activated carbon surface with dense functional groups formed by acid washing. TMA molecules react with the hydroxyl groups to form C−O−Al(CH3)2 species. Following release of H2O causes the reaction between H2O and AlCH3 to yield Al−OH species. It is noteworthy that the surface functional groups, such as hydroxyl groups, induced by acid washing can be straightforwardly employed for the reactive sites for ALD process. Furthermore, thermal annealing indispensably following the acid washing process in the traditional active carbon process can be excluded.

Figure 1c illustrates our Al2O3 deposited activated carbon. The capacitance of activated carbon (Cac) is connected to the capacitance of insulating layer (cil) in a serial way. The equivalent capacitance of activated carbon with insulating layer is represented as Ceq = Calc/CIL/CAC, which is always smaller than CAC. Therefore, CIL must be much larger than CAC in order to not to sacrifice the overall capacitance. Because of the very small distance (d) at C = εrε0A/d, this is possible if a high dielectric material is applied as an insulating layer.39

High-resolution transmission electron microscope (HRTEM) and elemental mapping were performed to investigate the structural and chemical modification of
activation carbon after ALD coating, as shown in Figures 1d. The surface of activated carbon was well-encapsulated with ultrathin amorphous layer with 2 nm thickness. Elemental mapping confirmed the existence of Al and O elements. Notably, conformal encapsulation with ultrathin Al₂O₃ layer did not cause any significant structural change in bulk morphology. As demonstrated in Figure 1b, the thickness of Al₂O₃ layer was controllable by the cycle number of ALD (see Figure S2 in the Supporting Information). A 2 nm thickness is chosen to avoid any capacitance reduction, as mentioned above.

We employed X-ray photoelectron spectroscopy (XPS) for the detailed chemical structure characterization. In Al 2p spectrum (Figure 2a), the peak at 74.3 eV is assigned to the formation of Al₂O₃ at surface of activated carbon. Deconvoluted C 1s XPS spectrum shows the two peaks around 285.3 and 287 eV, the former of which is assigned to the C−C bonding in disordered carbon. The peak at 287 eV corresponds to hydroxyl (C−OH) groups. In contrast to the XPS C 1s spectrum for activated carbon without Al₂O₃ layer (see Figure S3b in the Supporting Information), the peak intensities for oxygen function groups (C−OH at 287 eV, OH−C=O at 289 eV) decreased significantly. Table 1 summarizes the relative intensities normalized with C−C bond intensity. Obviously, Al₂O₃ layer substituted a lot of oxygen functional groups at the...
The surface area of ALD modified activated carbon was measured by N$_2$ (77.4 K) and Ar (87.3 K) adsorption/desorption. Bare activated carbon without Al$_2$O$_3$ layer was measured as a reference. As shown in Figure 2d, Ar isotherm presents the type I isotherm curve, which is typical for microporous solids. N$_2$ isotherm also showed an identical feature (see Figure S3c in the Supporting Information). Notably, ALT coating does not decrease surface area and pore volume significantly (from 1900 m$^2$ g$^{-1}$ and 0.9 cm$^3$ g$^{-1}$ to 1850 m$^2$ g$^{-1}$ and 0.86 cm$^3$ g$^{-1}$) (Table 2). Notably, such a minor change is also due to high density of Al$_2$O$_3$ rather than pore-filling by Al$_2$O$_3$ nanos. In addition, pore size distribution was obtained by using BJH (Barret–Joyner–Halenda) and HK (Horvath–Kawazoe) methods from the adsorption/desorption isotherms to clarify any pore blocking by ALT coating. The BJH shows that peak intensity of pore diameter of 2 nm decreased slightly but peak position was maintained the same value (Figure 2e and Figure S3d in the Supporting Information). The HK method available for micropore (d $\leq$ 2 nm) smaller than coating thickness did not detect any change in pore diameter after ALT coating (Figure 2f). Taken together, it is verified that highly conformal ALT Al$_2$O$_3$ layer does not block neither mesopore nor micropore channels of activated carbon.

Cyclic voltammogram (CV) in the extended potential range from 2.5 to 3.0 V (at 50 mV s$^{-1}$ @ 70 °C) was employed to evaluate electrochemical stability (Figures 3a-c). ALT coated activated carbon not only retained rectangular shape without significant distortion but also showed large total charge storage capacity ($Q_{tot}$) values (Figure 3d). This is attributed to the significant role of ALT layer to prevent the side reaction of electrolyte, which may increase of resistance of electrode interface. Consequently, the $Q_{tot}$ of ALT coated carbon continuously increased in a proportional way with charge potential, whereas the $Q_{tot}$ of bare activated carbon showed a minor enhancement, which is principally limited by the IR drop arising from interfacial resistance.

The electrochemical reversibility was compared by the relative ratio of anodic and cathodic charge ($Q_{a}/Q_{c}$) (Figure 3d). ALT coated activated carbon shows highly reversible electrochemical process represented by a low ratio of $Q_{a}/Q_{c}$ around 1.15. Surprisingly, almost constant $Q_{a}/Q_{c}$ was maintained up to 3 V, indicating negligible irreversibility. By contrast, bare activated carbon revealed significant irreversibility, which becomes even more serious with potential increase. On the basis of these results, a stable operating potential region for ALT-coated carbon could be extended up to 3 V.

The electrochemical properties of supercapacitor were analyzed in a pouch type cell with two electrodes and 1.0 M tetraethylammonium tetrafluoroborate (Et$_4$NBF$_4$) in acetonitrile electrolyte. We chose large pouch cell rather than coin cell to evaluate electrochemical properties under real application conditions, as shown in Figure S1b in the Supporting Information (electrode dimension: 30 × 42 mm, cell capacitance: 1 F). Particularly, charge voltages from 2.7 to 3.0 V were examined to assess high voltage stability, as suggested by CV results. The specific capacitance was evaluated by galvanostatic charge–discharge test shown in Figure 4a. The linear voltage–time curves exhibited a good capacitive behavior without any irreversible reaction. The specific capacitance was calculated by the equation $C_{sc} = \frac{I(T_2 - T_1)\Delta V}{Q_{tot}} = \frac{I(T_2 - T_1)(V_1 - V_2)m}{Q_{tot}}$, where $V_1$ and $V_2$ represent $V_{max0.8}$ and $V_{max0.4}$ V, respectively (based on IEC62391–1), $I = 0.5$ A g$^{-1}$ and $m$ is the weight of the two electrodes. The specific capacitance of supercapacitor with ALT-coated activated carbon was 37 F g$^{-1}$, which is almost same with that of activated carbon (38 F g$^{-1}$) (Figure 4a). This again confirms that porous structure was well-maintained without pore blocking during ALT coating. Further operation at a higher voltage significantly improved the energy density. Typically, while fully charged voltage increased to 3.0 V, energy density increased by at least 30% compared to 2.7 V operation.

Our activated carbon with significantly reduced functional groups at high surface area shows remarkable improvement for leakage current, which has remained as one of the most difficult technological problems for high performance supercapacitors. Self-discharge profile was examined in order to characterize any leakage current. After the supercapacitor was charged with a constant-voltage supply for 1 h, the open circuit voltage at the cell terminals was monitored for 50 h, as shown in Figure 4b. Surprisingly, even though 50 h passed after full charge to 3.0 V, it still retains 2.21 V (74% of initial voltage). By contrast, bare activated carbon showed 1.69 V (56% of initial voltage).

The principal source of self-discharge is faradic reactions at the electrode surface, as mentioned above. The surface oxygen functional groups (i.e., COOH, C≡O, COOR, C–OH) behave as active sites for electrochemical oxidation/reduction, when electrodes were excessively polarized in an anodic or cathodic direction in the electrolytic solution. As a majority of functional groups at activated carbon were replaced with the oxygen functional groups at activated carbon were replaced with the functional groups at high surface area shows remarkable improvement for leakage current, which has remained as one of the most difficult technological problems for high performance supercapacitors. Self-discharge profile was examined in order to characterize any leakage current. After the supercapacitor was charged with a constant-voltage supply for 1 h, the open circuit voltage at the cell terminals was monitored for 50 h, as shown in Figure 4b. Surprisingly, even though 50 h passed after full charge to 3.0 V, it still retains 2.21 V (74% of initial voltage). By contrast, bare activated carbon showed 1.69 V (56% of initial voltage).

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with severe side effects such as capacitance reduction.39 By contrast, our approach works even better for reducing leakage under high voltages over 3 V.

Another crucial requirement for high voltage stability is the cycle-ability at high voltage operation. In this work, supercapacitors were fully charged-discharged from 0 to 3.0 V for 5 K cycles at 70 °C. In such an accelerated cycle test at a high temperature, Arrhenius model is generally used to extrapolate the temperature dependence of life (rate of a chemical reaction $K = A \exp(-E_a/RT)$, where $A$, $E_a$, $R$, and $T$ are the constant, activation energy, gas constant, and temperature in Kelvin, respectively).16,49,50 It is commonly regarded that the cycle life is halved for every 10 °C increase. On the basis of this assumption, we can regard that 5 K cycles at 70 °C can be converted into 120 K cycles at room temperature. Notably, supercapacitors based on our ALD coated activated carbon exhibited excellent stability despite the extreme test condition (Figure 4c). After 5 K constant current charge/discharge cycles at current density of 1 A g$^{-1}$, 88% of its initial capacitance was retained. By contrast, the supercapacitors based on bare activated carbon declined down to 75% along with a rapid decay within 200 cycles. Furthermore, the swelling phenomenon of supercapacitors in high voltages causes severe problems such as leakage, pollution, and breakdown. Practically, supercapacitors based on bare activated carbon were swollen extremely (Figure 4c inset, Table 2), some of which indeed show electrolyte leakage and breakdown. By contrast, supercapacitors with protective ALD coating layer well-preserved original dimension without any swelling, verifying that the surface of activated carbon was perfectly protected against side effects from electrolyte.

Electrochemical impedance spectroscopy (EIS) analysis has been recognized as one of the principal characterization methods for supercapacitors.10,50−52 Impedance of both bare and ALD coated samples were measured after first and 5000th cycles in the frequency range of 500 kHz −5 MHz (Figure 4d, Table 2). At high frequencies, the intercept at real part (Re) is a combinational resistance of ionic resistance of electrolyte, intrinsic resistance of substrate and contact resistance at the active material/current collector interface. This value is almost same for both samples. A major difference was the semicircle in the high-frequency range shown in the inset, which corresponds to the charge-transfer resistance ($R_{ct}$). The $R_{ct}$ is generated mainly from the charge transfer at the contact interface between the electrode and electrolyte. It can be calculated from the diameter of semicircle and geometric area of the electrodes (12.6 cm$^2$). After the first cycle, a resistance of 0.92 Ω cm$^2$ was calculated, which is larger than 0.53 Ω cm$^2$ for supercapacitor based on bare activated carbon (see Figure S4c in the Supporting Information). This is attributed to the resistance of Al$_2$O$_3$ layer. After 5 K cycles (Figure 4d), $R_{ct}$ was measured to be 1.05 Ω cm$^2$ for ALD coated electrodes, which is almost same with initial value. By contrast, $R_{ct}$ for bare activated carbon was significantly increased up to 1.84 Ω cm$^2$. Undesired reaction involved with electrolyte degradation occurred in such a rapid way without any protective layer.

The chemical structure of electrode after 5 K cycles was characterized by XPS. Typical elements for the byproduct Figure 3. (a–c) Cyclic voltammograms, (d) total charge ($Q_{tot}$) and the ratio of anodic to cathodic charge ($Q_a/Q_c$) according to potential range change at 50 mV s$^{-1}$@70 °C.

1903

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generated from the decomposition of Et$_4$N$^+$ and BF$_4^-$ ions are B and N, respectively. XPS B 1s and N 1s spectra are shown in Figure 4e, f. The surface density of B and N were observed much less at the surface of ALD coated activated carbon. The peak intensity of N is approximately one-third of that for bare carbon electrodes, whereas B was hardly detected at all. These results indicated that Al$_2$O$_3$ layer indeed offers a protective interface between electrode and electrolyte, which can indeed avoid the unnecessary decomposition of electrolytes.

### CONCLUSIONS

We have demonstrated ultrathin 2 nm-thick Al$_2$O$_3$ encapsulation of activated carbon by ALD for ultrahigh performance supercapacitor with remarkable stability at high operating voltages. Although ALD encapsulation well-maintains the meso- and microporous structure of activated carbon without filling accessible pore channels, it greatly reduces the processing time for electrode fabrication by eliminating time-consuming thermal annealing and vacuum drying process. Significantly, ALD deposited Al$_2$O$_3$ layer effectively protected oxygen functional groups that cause faradaic degenerative reaction of...
electrolytes. Consequently, carbon electrodes were protected from undesirable reactions involved with electrolytes and exhibited excellent retention for charge/discharge cycles. This ALD-assisted stabilization is a general solution to the low-energy-density problem of activated-carbon-based supercapacitors. The resultant supercapacitor attains not only high power but also high energy density for more diversified applications.

**MATERIALS AND METHODS**

**Synthesis of Activated Carbon.** Coke (JX NOE) was first mixed with KOH powder mechanically (weight ratio of coke to KOH is 1:4). For alkali activation, the coke/KOH mixture was put in a tubular furnace under flowing N₂ and annealed at 750 °C for 1 h. Then heat-treated powder was washed with the mixture with diluted HCl and water subsequently, followed by a drying step to obtain activated carbon (but, in conventional method, annealing step has to be repeated again at a temperature higher than activation temperature after drying step, see Figure S1a in the Supporting Information).

**Fabrication of Electrode.** The electrode was prepared by casting slurries containing 80 wt % of AC, 10 wt % of acetylene black, 10 wt % of SBR/PTFE/CMC mixed in deionized water on Al foil (20 μm thickness); however, in the conventional method, it is necessary that the electrode was dried under vacuum over 24 h at 120 °C.

**Atomic Layer Deposition.** ALD layers were grown directly on activated carbon powders using a reactor. The tetramethyldialumini- num (TMA, EG chem.) and high performance liquid chromatography grade H₂O (HPLC, Sigma-Aldrich) were used as precursors. The typical growth rate for the chemistry is 1.1 Å per cycle. The reaction sequence was: (i) exposure of TMA, (ii) purge to remove the nonreacted precursors and the byproducts, (iii) exposure of H₂O, (iv) purge to remove the nonreacted precursors and the byproducts. ALD was conducted at 180 °C.

**Electrochemical Measurements.** The pouch-type cells were assembled to evaluate the electrochemical performances (see Figure S1b in the Supporting Information). One pair of cathode/anode electrodes with the dimension of 30 × 42 mm were stacked in a cell (14) Obreja, V. V. N. On the Performance of Supercapacitors with Organic Electrolytes. Adv. Mater. 2010, 22, E235–E241.

**CHARACTERIZATION**

The surface morphologies and microstructures were characterized by high-resolution transmission electron microscope (HRTEM, JEOL JEM-2100F). The chemical functional groups and byproducts on the surfaces were characterized by X-ray photoelectron spectroscopy (XPS, Thermo Scientific Sigma Probe) and Boehm titration. The specific surface area, pore volume, and pore size distribution were obtained from Ar adsorption/desorption (Micrometrics, ASAP 2020).

**ASSOCIATED CONTENT**

Supporting Information

The photograph and schematic diagram of test cell, TEM · XPS · Boehm data for bare activated carbon, N₂ adsorption/desorption analysis, and electrochemical data in the voltage range of 0–2.7 V. This material is available free of charge via the Internet at http://pubs.acs.org.

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**Notes**

The authors declare no competing financial interest.

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